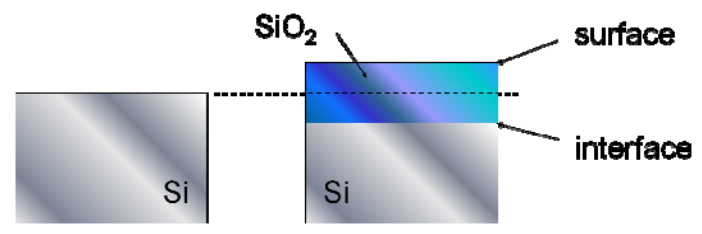
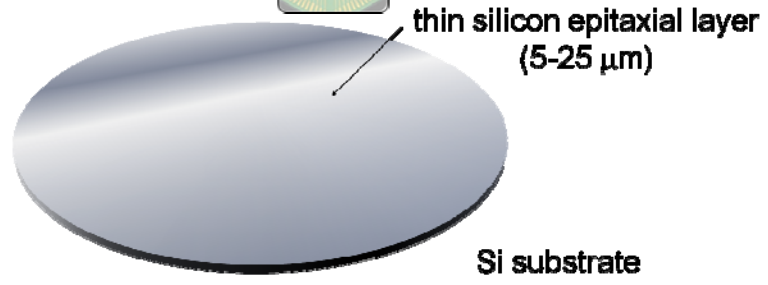
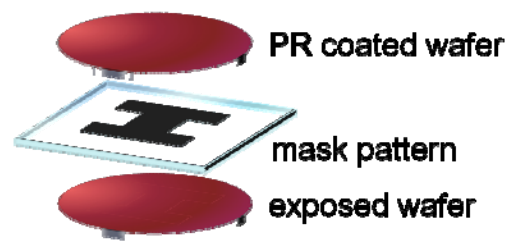


IIIA	IVA	VA
5 <b>B</b>	6 <b>C</b>	7 <b>N</b>
13 <b>Al</b>	14 <b>Si</b>	15 <b>P</b>
31 <b>Ga</b>	32 <b>Ge</b>	33 <b>As</b>
49 <b>In</b>	50 <b>Sn</b>	51 <b>Sb</b>

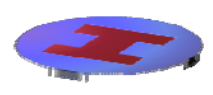
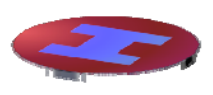


bare oxidized wafer



negative resist

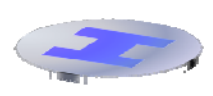
positive resist



developed wafers



after etching



after stripping

